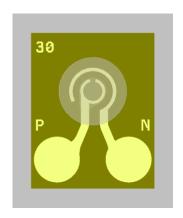
# 25Gbps GaAs PIN Photodiode & Array

P/N: DO313\_30um\_G25 (\_1x4, \_1x8, \_1x12 for arrays)





#### Introduction

#### PRELIMINARY DATASHEET

These high performance products are front side illuminated GaAs PIN photodiode arrays that feature low capacitance, high responsivity, and extreme low dark current with proven excellent reliability in field. These products have 30µm detection window; with the integrated lens, the effective aperture size is increased to 40µm. These products are primary designed to meet the performance requirements for 25Gbps short range optical data communication, with its chip dimensions specially tailored to meet the packaging requirement for 25Gbps/channel module or Active Optical Cable (AOC) receiver operating at 850nm. 1x4, 1x8 and 1x12 array are all provided.

## **Key Features**

- 40um effective aperture size with the integrated lens.
- Excellent low dark current and capacitance
- -40C to 85C operation range
- Suitable for non-hermetic package
- Customization for 1x4, 1x8 and 1x12 array configuration
- Different pad sequence available.
- Highly robust 4" GaAs IC wafer fab with fast cycle-time
- Deliverable with 100% testing and inspection
- RoHS compliant

### SPECIFICATIONS (T=25C°)

## **Applications**

- 25Gbps AOC (Active Optical Cable) receiver at 850nm
- 25G SFP+
- 4x25G QSFP

	Conditions	Min.	Typical	Max.	Unit	Notes
Bandwidth	-2V	-	23	-	GHz	
Wavelength range		760	850	860	nm	
Capacitance	-3 V	-	0.10	0.12	pF	
Responsivity	@850 nm	0.5		0.6	A/W	
Dark current	-3V	-	<0.1	0.3	nA	
Reverse Breakdown	-20V	-	-	1	μΑ	

#### **ABSOLUTE MAXIMUM RATING**

Parameter	Rating
Operating Temperature	-40C to 85C
Storage Temperature	-55C to 125C
Forward Current	10mA

## **Global Communication Semiconductors, LLC**

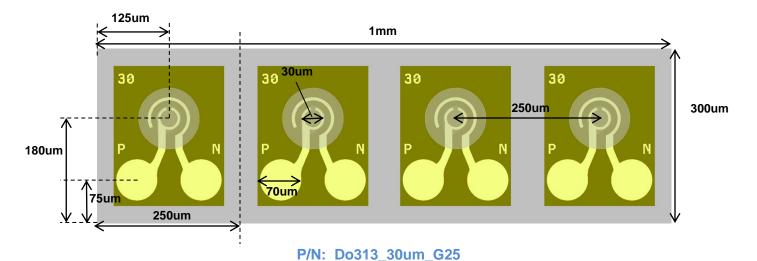


Made in USA

#### **DIMENSIONS**

	Conditions	Min.	Typical	Max.	Unit	Notes
Detection window		-	30	-	μm	40um effective window with the integrated lens
Die pitch		-	250	-	um	
Bonding pad diameter		-	70	-	μm	for both p- and n- pads
Die height		140	150	160	μm	
Die width		290	300	310	μm	
Die length			250		um	For single PIN
			1		mm	For 1x4 Array
			3		mm	For 1x12 Array

#### **BONDING PAD CONFIGURATION**



Attention: GaAs material and electrostatic sensitive device, observe precaution for handling.

#### **About GCS:**

GCS has a long history manufacturing and shipping both GaAs and InGaAs based photo diodes since 2000. Our state of art manufacturing facility is located in Torrance, California, and has about 10,000 square feet of fab space with a capability of about 1200 4-inch wafers per month and expandable to 2000 wafers per month. GCS as a world-class semiconductor device manufacturer has been delivering a total of over 30 million photo diodes with various date rates and applications used for optical communications, which have been deployed in field by top tier optical transceiver companies worldwide.

## Global Communication Semiconductors, LLC

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